

NONPROVISIONAL PATENT APPLICATION**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

OLIFF & BERRIDGE, PLC
P.O. Box 19928
Alexandria, Virginia 22320
Telephone: (703) 836-6400
Facsimile: (703) 836-2787

Attorney Docket No.: 105732

Date: May 31, 2000

BOX PATENT APPLICATION**NONPROVISIONAL APPLICATION TRANSMITTAL
RULE §1.53(b)**

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

Transmitted herewith for filing under 37 C.F.R. §1.53(b) is the nonprovisional patent application

For (Title): ROLL HAVING GLASS COATINGBy (Inventors): Christopher D. BLAIR and Timothy R. JASKOWIAK

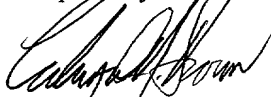
- ☒ Formal drawings (Figs. 1-3; 3 sheets) are attached.
☒ A Declaration and Power of Attorney is filed herewith.
☒ An assignment of the invention to XEROX Corporation is filed herewith.
☐ An Information Disclosure Statement is filed herewith.
☐ A Preliminary Amendment is filed herewith.
☐ Please amend the specification by inserting before the first line the sentence --This nonprovisional application claims the benefit of U.S. Provisional Application No. _____, filed _____.--
☒ The filing fee is calculated below:

**CLAIMS IN THE APPLICATION AFTER ENTRY OF
ANY PRELIMINARY AMENDMENT NOTED ABOVE**

FOR:	NO. FILED	NO. EXTRA	RATE	FEE
BASIC FEE				\$ 690
TOTAL CLAIMS	41 - 20	= 21	x 18	\$ 378
INDEP CLAIMS	3 - 3	= 0	x 78	\$
<input type="checkbox"/> MULTIPLE DEPENDENT CLAIMS PRESENTED			+260	\$
* If the difference is less than zero, enter "0".			TOTAL	\$1068

- ☒ Please charge Deposit Account No. 24-0037 in the amount of \$1068. Two duplicate copies of this sheet are enclosed.
☒ The Director is hereby authorized to charge any other fees that may be required to complete this filing, or to credit any overpayment, to Deposit Account No. 24-0037. Two duplicate copies of this sheet are attached.

Respectfully submitted,


James A. Oloff
Registration No. 27,075

Edward A. Brown
Registration No. 35,033

JAO:EAB/ldg

Date: May 31, 2000

JC625 U.S. PTO
09/584373
05/31/00

Inventor Information

Inventor One Given Name:: Christopher
Family Name:: D.
Name Suffix:: BLAIR
City of Residence:: Ontario
State or Prov. of Residence:: New York
Country of Residence:: USA
Inventor Two Given Name:: Timothy
Family Name:: R.
Name Suffix:: Jaskowiak
City of Residence:: Webster
State or Prov. of Residence:: New York
Country of Residence:: USA
Inventor Three Given Name::
Family Name::
Name Suffix::
City of Residence::
State or Prov. of Residence::
Country of Residence::
Inventor Four Given Name::
Family Name::
Name Suffix::
City of Residence::
State or Prov. of Residence::
Country of Residence::
Inventor Five Given Name ::
Family Name::
Name Suffix::
City of Residence::
State or Prov. of Residence::
Country of Residence::

Correspondence Information

Name Line One:: Oliff & Berridge PLC
Address Line One:: P.O. Box 19928
City:: Alexandria
State or Province:: VA
Postal or Zip Code:: 22320
Telephone:: (703) 836-6400
Fax:: (703) 836-2787
Electronic Mail:: commcenter@oliff.com

Application Information

Title Line One:: ROLL HAVING GLASS COATING
Title Line Two::
Title Line Three::
Title Line Four::

ROLL HAVING GLASS COATING

BACKGROUND OF THE INVENTION1. Field of Invention

5 This invention relates to rolls, such as for use in electrostatographic imaging devices.

2. Description of Related Art

Electrostatic reproduction involves uniformly charging a photoconductive member, or photoreceptor, and imagewise discharging it, or imagewise exposing it,
10 based on light reflected from an original image being reproduced. The result is an electrostatically-formed latent image on the photoconductive member. The latent image is developed by bringing a charged developer material into contact with the photoconductive member.

Two-component and single-component developer materials are known.
15 Two-component developer materials comprise magnetic carrier particles and charged toner particles that adhere triboelectrically to the carrier particles and are intended to adhere the photoconductive member.

A single-component developer material typically consists of only toner particles. The toner particles typically have an electrostatic charge to adhere to the
20 photoconductive member, and magnetic properties to magnetically convey the toner particles from the sump to the magnetic roll. The toner particles adhere directly to the donor roll by electrostatic charges. The toner particles are attracted to the donor roll from a magnet or developer roll. From the donor roll, the toner is transferred to the photoconductive member in the development zone.

25 For both types of developer material, the charged toner particles are brought into contact with the latent image to form a toner image on the photoconductive member. The toner image is transferred to a receiver sheet, which passes through a fuser device where the toner particles are heated and permanently fused to the sheet, forming a hard copy of the original image.

30 A development device is used to bring the charged toner particles into contact with the latent image formed on the photoreceptor, so that the toner particles adhere electrostatically to the charged areas on the latent image. The development device typically includes a chamber in which the developer material is mixed and charged.

One type of two-component development method and apparatus is known as "scavengeless development." In scavengeless development systems, toner is detached from the donor roll by applying an alternating current (AC) electric field to electrodes disposed between the donor roll and the photoconductive member. There is no physical contact between the development apparatus and the photoconductive member. Scavengeless development is useful in apparatus in which different types of toner are supplied to the same photoconductive member.

"Hybrid" scavengeless development apparatus typically includes a mixing chamber that holds a two-component developer material, a developer material developer or magnetic roll, a donor roll, a development zone, and an electrode structure at the development zone between the donor roll and the photoconductive member. The donor roll receives charged toner particles from the developer roll and transports the particles to the development zone. An AC voltage is applied to the electrodes to form a toner cloud in the development zone. Electrostatic fields generated by an adjacent latent image on the photoconductive member surface attract charged toner particles from the toner cloud to develop the latent image on the photoconductive member.

Another variation on scavengeless development uses single-component developer material development systems. As in two-component developer material development systems, the donor roll and electrodes also create a toner cloud.

SUMMARY OF THE INVENTION

In both one-component and two-component developer scavengeless development systems, the electrical, chemical and physical characteristics of the donor roll affect the ability of the development apparatus to effectively transport toner particles into the development zone and to achieve high-quality image development. The donor roll should have characteristics that enable charged toner particles to effectively and controllably adhere electrostatically to the donor roll's outer surface, and be donated to the photoconductive member. It is desirable that the electrical properties of the donor roll be uniform and also tunable. It is also desirable that the donor roll be able to withstand wear and harmful chemicals.

The donor roll outer surface should also have sufficient mechanical properties, including wear resistance, to withstand wear and other types of degradation during service.

5

10

15

20

25

30

The properties of the coating make the rolls suitable for use in an electrostatographic imaging apparatus, such as for use in hybrid scavengeless development.

The coatings of the rolls can be applied onto substrates such as cores using conventional coating techniques. Further, the coatings can be processed using conventional finishing techniques.

Exemplary embodiments of the methods of forming the rolls according to this invention comprise applying a glass coating over a core. The coating can be applied over the core by any suitable glass coating process.

BRIEF DESCRIPTION OF THE DRAWINGS

Preferred embodiments of this invention will be described in detail, with reference to the following figures, in which:

Fig. 1 illustrates a scavengeless electrostatographic development apparatus including an exemplary embodiment of a donor roll according to this invention;

Fig. 2 illustrates a two-component, hybrid scavengeless development device including an exemplary embodiment of a donor roll according to this invention; and

Fig. 3 illustrates an exemplary embodiment of a donor roll according to this invention including a glass coating.

DETAILED DESCRIPTION OF PREFERRED EMBODIMENTS

Fig. 1 shows a scavengeless electrostatic imaging apparatus 10 including an exemplary embodiment of a donor roll 54 according to this invention. The imaging apparatus 10 includes an image bearing member in the form of a belt 12 having an outer photoconductive surface 14. The image bearing member can alternatively comprise other types of photoconductive image bearing members, such as a drum having a photoconductive surface. The belt 12 moves in the direction of the arrow 16 to advance successive portions of the photoconductive surface 14 sequentially through various processing stations during the imaging process. The belt 12 is driven by a motor 18.

Initially, a portion of the belt 12 passes through a charging station 30 where a power supply 32 causes the corona generating device 34 to charge a portion of the photoconductive surface 14 of the belt 12.

The charged portion of the belt 12 is advanced to a exposure station 40. At the exposure station 40, one or more light sources such as lamps 42 emit light that is reflected onto an original document 44 seated on a transparent platen 46. The light reflected imagewise from the original image of the document 44 is transmitted

5

10

15

20

25

30

chamber 156 into contact with electrode wires 155 within a development zone 164 for latent image development. The developer material 160 is moved and mixed within the mixing chamber 156 by a mixing device 166 to charge the carrier beads and toner particles. The oppositely charged toner particles adhere triboelectrically to the charged magnetizable carrier beads.

The development apparatus 152 also includes a developer material feeder assembly, such as a magnetic roll 168, that feeds a quantity of the developer material 160 from the mixing chamber 156 to the donor roll 154. The magnetic roll 168 includes a substrate 170. The substrate 170 rotates in the direction of the arrow 172, and includes a coating 174, and magnetic members M1 to M4. The magnetic roll 168 and the donor roll 154 are electrically biased relative to each other so that charged toner particles of the developer material 160 fed to the donor roll 154 are attracted from the magnetic roll 168 to the donor roll 154.

In some other embodiments, the coating 174 is not needed on the substrate 170 to provide the desired transport properties. In addition, the substrate 170 can include a different number of magnetic members than the four magnetic members M1 to M4 in Fig. 2.

As also shown in Fig. 2, the donor roll 154 is biased to a specific voltage by a direct current (DC) power supply 176 so that the donor roll 154 attracts charged toner particles from the magnetic roll 168 in a nip 178. To enhance the attraction of charged toner particles from the mixing chamber 156, the magnetic roll 168 is also biased by a DC voltage source 180. The magnetic roll 168 is also biased by an AC voltage source 182 that temporarily loosens the charged toner particles from the magnetized carrier beads. The loosened charged toner particles are attracted to the donor roll 154. An AC bias is also applied to the electrode wires 155 by an AC voltage source 184 to loosen charged toner particles from the donor roll 154, and to form a toner cloud within the development zone 164.

Other embodiments of the hybrid scavengeless two-component development apparatus 152 can comprise more than one donor roll 154, such as, for example, two donor rolls 154. Such apparatus can also include more than one magnetic roll 168 and more than one mixing device 166.

The donor roll 154 can also be used in scavengeless single-component development apparatus.

The donor roll 154 is an example of one type of roll encompassed by this invention. As described below, the rolls according to this invention can be used in other types of rolls as well.

As shown in Fig. 3, exemplary embodiments of the donor rolls 154 according to this invention include a core 1541 and a coating 1542 formed over the core 1541. The coating 1542 is typically formed directly over the core 1541. The coating 1542 typically also defines the outer surface of the donor roll 154.

However, embodiments of the donor roll 154 can include one or more layers between the core 1541 and the coating 1542. For example, a metal layer may be formed over the core 1541 and the coating 1542 formed over the metal layer. Other suitable layers can also be formed between the core 1541 and coating 1542.

In addition, embodiments of the donor roll 154 can comprise a suitable surface coating applied over the coating 1542. Such optional coatings are described, for example, in U.S. Patent Application No. 09/503,936 filed on February 14, 2000 and incorporated herein by reference in its entirety.

The core 1541 can comprise any suitable material that has desired electrical conducting properties. In embodiments, the material forming the core 1541 should preferably be able to withstand the temperatures that are typically reached during the process of coating the core 1541, as described in detail below.

The core 1541 can be formed, for example, of any suitable metallic materials, non-metallic materials, or combinations thereof. Ferrous materials such as plain carbon steels and stainless steels can be used to form the core 1541. In addition, non-ferrous materials such as aluminum and aluminum alloys, and copper-based materials such as brass, can be used to form the core 1541. These non-ferrous materials have a higher coefficient of thermal expansion than steels.

Further, non-metallic materials such as glass, composites and ceramics can be used to form the core 1541. For the non-metallic core materials, the core 1541 and coating 1542 are electrically grounded.

In exemplary embodiments, the core 1541 can be formed of one of the above-described non-metallic materials and one or more metal layers can be formed on the non-metallic core to provide a suitable surface for applying the coating 1542. For example, a ceramic core 1541 can be coated with any suitable metal such as, for example, aluminum, and the coating 1542 can be applied over the metal coating.

In embodiments, it is contemplated that suitable glasses having relatively low coefficients of thermal expansion could be applied over cores formed of materials that have relatively low coefficients of thermal expansion, such as ceramics and low carbon steels.

5 The core 1541 is typically cylindrical shaped. However, other suitable shapes can be used, as desired. For example, it is contemplated that the glass coatings 1542 could be applied on endless belts, such as photoreceptor belts. In such embodiments, the glass coatings 1542 could be very thin, e.g., of a submicron thickness, so that the glass coatings 1542 are pliable like the endless belt.

10 According to this invention, the coating 1542 formed on the core 1541 is composed of a glass material. In certain exemplary embodiments of the donor roll 154 according to this invention, the coating 1542 can consist essentially of glass. In other exemplary embodiments of the donor roll, the coating 1542 can comprise one or more additives to control selected ones of the electrical, mechanical, thermal and
15 chemical properties of the coating 1542.

 The composition of the glass material of the coating 1542 is selected to provide the desired properties to the coating 1542. One consideration in selecting the glass material composition is the desired thermal properties of the outer coating 1542. In embodiments of the donor roll 154, the coating 1542 can have a coefficient of
20 thermal expansion that closely matches the coefficient of thermal expansion of the substrate on which the coating 1542 is formed. For example, the respective coating 1542 and core 1541 compositions can be selected such that their respective coefficients of thermal expansion differ by less than about 1 ppm/°C. Preferably, the coefficients of thermal expansion of the coating 1542 and core 1541 differ by as small
25 of a value as possible. By closely matching the coefficients of thermal expansion of the core 1541 and coating 1542, a good seal can be formed between the coating 1542 and the core 1541. It is also desirable that the glass material formed on the core 1541 have resistance to thermal induced degradation, and to failure caused by repeated thermal cycling of the coating 1542 during normal operation of the donor roll 154.

30 Another consideration in selecting the composition of the glass material is that it have the desired electrical properties to enable the coating 1542 to be sufficiently electrically charged and discharged to provide improved performance.

It is also desirable that the coating 1542 have uniform electrical properties throughout its volume so that it can be uniformly electrically charged and discharged.

Another consideration in selecting the composition of the glass material of the coating 1542 is that the glass material have the desired mechanical properties for use in the donor roll 154. These mechanical properties typically include suitable hardness, wear resistance against abrasion, strength and ductility.

Another consideration in selecting the composition of the glass material of the coating 1542 is that the glass material have the desired chemical resistance.

Generally, the glass coatings 1542 are highly chemical resistant. When used in electrostatographic imaging apparatus, the glass coatings 1542 are preferably resistant to toner, paper fibers and other substances commonly found in these environments.

A suitable exemplary material for forming the coatings 1542 in view of the above-described considerations is sodium silicate glass. Sodium silicate glass provides desirable properties. In addition, these glasses are inexpensive and easier to process than some other types of glass such as germanate, borate and phosphate glasses. Sodium is included in sodium silicate glass to modify its electrical properties. Generally, the conductivity of sodium silicate glass increases as a function of increasing soda concentration. However, the amount of soda in the sodium silicate glass material is controlled to prevent phase separation, which would result in sodium droplets in a silica matrix. Such phase separation can occur if the soda concentration is decreased to below about 7 mol% of soda.

The coefficient of thermal expansion of sodium silicate glass increases slightly as a function of soda concentration. The melting point of sodium silicate glass decreases significantly with an increase of the soda content.

According to this invention, other glasses can be used in addition to sodium silicate glass to form the coating 1542. For example, germanate and borate glasses do not undergo phase separation with increasing soda concentration. Phosphate glasses have higher coefficients of thermal expansion and thermal conductivity than sodium silicate glass or any other type of glass. These glasses, as well as lithium glasses, can also be used in exemplary embodiments of the coating 1542.

As stated above, additives can be included in the glass materials forming the coating 1542 in order to tune its properties, including one or more of its electrical, mechanical, thermal and chemical properties. For example, metals, generally in the

form of metal oxides, can be added to the glass material to tailor its coefficient of thermal expansion and electrical conductivity. The metals can also be added to vary the color of the glass. Exemplary metal oxides that can be included in the glass material include, but are not limited to, oxides of Na, Al, Si, P, K, Ti, V, Cr, Fe and Ni. In addition, one or more elements such as Ni, Ag, Au, Li, Rb, Cs, Mg, Ca, Sr, Ba, Y, Sc, Mn, Co, Cu, Pb and Bi can be added to the glass material.

The conductivity of the glass material forming the coating 1542 can be tuned by including one or more of the metal oxides in selected amounts. Soda, Na_2O , is effective because it has a relatively small size and good mobility within the glass material. However, soda also raises the coefficient of thermal expansion and decreases the durability and hardness of the glass material. Other substances can be added to compensate for the effect of soda and enhance the durability of the glass material. For example, aluminum oxide or calcium oxide (lime) can be added to the melt to increase durability. However, these additives can decrease both the conductivity and thermal expansion of the glass material. Accordingly, the one or more additives that can be included in the glass material can be selected based on their individual effects so as to achieve the overall desired properties of the glass material. The overall desired properties of the glass material are typically based on the properties of the core 1541 on which the glass material is formed and the intended application of the roll 154.

For example, aluminum cores 1541 have a high coefficient of thermal expansion. Accordingly, the glass materials formed on aluminum cores 1541 should also have a high coefficient of thermal expansion in order to closely match that of the aluminum core 1541, so that a good seal can be formed between the core 1541 and the coating 1542.

As stated above, coatings 1542 can also be formed on cores 1541 that have lower coefficients of thermal expansion than aluminum and other like metals. For example, such cores can comprise steels. The composition of the glass material can be selected so that the coating 1542 forms a good seal on the core 1541 composed of such metals.

The glass material forming the coating 1542 can also provide the desired electrical properties. The glass materials have amorphous structures. Consequently, the electrical properties of the glass material can be more closely controlled than for

crystalline materials having grain boundaries, including ceramic materials. The glass materials can provide improved control of the electrical properties throughout the coatings, i.e., improved uniformity of the electrical properties.

The glass material forming the coating 1542 can provide the desired mechanical properties. Desired mechanical properties of the coating 1542 include a suitably high hardness, wear resistance and toughness. The glass coatings 1542 typically have a Knoop hardness number of at least about 4 GPa (4 GPa Knoop).

The surface smoothness of the coating 1542 can be quantitatively characterized by known surface roughness measurement and characterization equipment and techniques. In embodiments of the coating 1542, the surface of the coating 1542 can have a maximum waviness Wt of less than about 1 μm and a surface smoothness or arithmetical mean roughness Ra of less than about 0.75 μm after completion of all finishing operations on the coating 1542. In other embodiments of the coating 1542, the surface of the coating 1542 can be even smoother and can have a maximum waviness Wt of less than about 0.1 μm , and a surface smoothness or arithmetical mean roughness Ra of less than about 0.1 μm , after all finishing operations have been performed on the coating 1542.

In addition, the glass material of the coating 1542 can be easily prepared to the desired surface finish characteristics. The glass materials can be machined, such as by conventional grinding processes, to a smooth, i.e., low roughness, finish.

In addition, the smooth surface finishes provided by glass coatings 1542 reduce machining cycle times. First, glass materials have a smoother surface in the as-deposited state than some known ceramic materials formed by processes such as plasma spraying. In addition, the machining cycle time for the coatings 1542 can be significantly lower than that required for some known ceramic coatings, such as alumina coatings. This high cycle time for such ceramic coatings is necessitated by the slow traverse speed and small depth of cut that must be used in grinding them, due to their multi-grained structures and relatively high hardness.

The glass material forming the coating 1542 can provide the desired thermal properties. The glass material forming the coating 1542 can also provide the desired thermal expansion properties. The thermal expansion coefficient of the coating 1542 is important to enable a satisfactory bonding of the coating 1542 onto a substrate. As described below, the substrate has a metal surface on which the coating 1542 is

applied. The thermal expansion coefficient of the coating 1542 is selected to match as closely as possible the thermal expansion coefficient of the metal surface. By closely matching the thermal expansion coefficients, a good glass-to-metal bond can be achieved.

The glass material forming the coating 1542 can also provide the desired chemical resistance properties. The glass materials need to be able to withstand exposure to chemicals including liquids, solids and gases that are typically present in the environments in which the rolls are used. For example, in electrostatographic imaging device, chemicals that are typically found and that are harmful to some materials include, for example, toner, paper fibers, developer fluid and fuser oil. The glass materials forming the coatings 1542 can provide good resistance to these and other chemicals, and thus prolong the service life of the rolls 154.

As stated above, the composition of the coating 1542 can be selected to provide the desired properties to the donor roll 154. Regarding the electrical properties, the electrical resistivity of the coating 1542 can be from about $1 \times 10^4 \Omega \cdot \text{cm}$ to about $1 \times 10^{14} \Omega \cdot \text{cm}$. In some embodiments, the electrical resistivity of the coating 1542 is preferably from about $1 \times 10^4 \Omega \cdot \text{cm}$ to about $1 \times 10^6 \Omega \cdot \text{cm}$.

The time constant (i.e., capacitance x resistivity) of the coating 1542 is dependent on the coating thickness, as both the electrical resistivity and capacitance include a length dependant term. Accordingly, in electrostatographic imaging applications, the final coating thickness can be selectively varied to provide a roll that is well suited for given machine requirements. In addition, the revolution speed of the roll can also be changed to accommodate different coating resistivities, which ultimately effects the machine printing rate.

Suitable glass materials for forming the coating 1542 are commercially available from Ferro, Inc., Coatings and Color Division, located in Cleveland, Ohio. The glass materials are typically provided in slurry or powder form. For slurries of the glass materials, the slurries preferably comprise particles having a size of less than about $100 \mu\text{m}$. Machining, such as by ball milling or the like, can be used to achieve smaller particle sizes, if desired.

An exemplary sodium silicate glass composition and exemplary ranges of the amounts of the components of the glass material are as follows: silica (SiO_2), from about 40 mol% to about 95 mol%; soda (Na_2O), from about 5 mol% to about 60

mol%; alumina (Al_2O_3), from 0 to about 7 mol%; phosphate (P_2O_5), from 0 to about 5 mol%; potash (K_2O), from 0 to about 10 mol%; titania (TiO_2), from 0 to about 20 mol%; vanadium penta-oxide (V_2O_5), from 0 to about 10 mol%; chromia (Cr_2O_3), from 0 to about 8 mol%; iron oxide (Fe_2O_3), from 0 to about 5 mol%; nickel, from 0 to about 5 mol%; silver, from 0 to about 5 mol%; and gold, from 0 to about 5 mol%.

That is, silica and soda are the only components in the above group of components that are required in every sodium silicate glass composition according to exemplary embodiments of this invention. The remaining components in the above group (i.e., alumina, phosphate, potash, titania, vanadium penta-oxide, chromia, iron oxide, Ni, Ag and Au) can be selectively added in the above molar percentages, or not included, in various exemplary embodiments, depending the desired properties of the coating 1542 formed from the glass material.

The above-described group of components of the soda silicate glass can provide an electrical resistivity of from about $1 \times 10^5 \Omega\cdot\text{cm}$ to about $1 \times 10^{14} \Omega\cdot\text{cm}$, and a time constant of from about 1.5×10^{-7} seconds for a coating thickness of about 25 μm at $1 \times 10^5 \Omega\cdot\text{cm}$, to about 3×10^2 seconds for a coating thickness of 200 μm at $1 \times 10^{14} \Omega\cdot\text{cm}$. The lower electrical resistivity of $1 \times 10^5 \Omega\cdot\text{cm}$ is a theoretical value based on an approximate 50 mol% Na_2O – 50 mol% SiO_2 glass composition. This particular glass would have a lower coefficient of thermal expansion and would be suitable for coating cores having a similar low coefficient.

An exemplary suitable glass material composition that can be applied on aluminum cores 1541 to form the outer coating 1542 is QP732, manufactured by Ferro Inc. This particular material comprises oxides of Na, Al, Si, P, K, Ti, V, Cr, Fe and Ni suspended in water. QP 732 has a very high coefficient of thermal expansion of about 23 ppm/K for a glass material, making it suitable for forming an outer coating 1542 on cores 1541 formed of aluminum and like materials.

The coating 1542 can be applied onto the core 1541 by any suitable coating process. Suitable processes for forming the coatings include, for example, electrostatic spraying, wet coating, dip coating, plasma spraying and vacuum deposition. For electrostatic spraying processes, the glass material is applied onto the core by electrostatic spray while the core 1541 is electrically grounded and typically rotated to promote uniform coverage of the glass material on the core 1541. Electrostatic spraying process parameters include the electrostatic spray feed rate, the

core rotation rate, the spray device traverse speed relative to the core 1541, and the number of spray passes. These process parameters can be selected to control the coating uniformity and thickness of the coating 1542.

For wet spraying techniques, the glass material can be formed into a slurry and applied by any suitable wet spraying technique. The resulting coating 1542 is typically adhered onto the core 1541 at an elevated temperature. For example, the elevated temperature can be from about 480°C to about 900°C.

For melt flow coating techniques, the glass material can be formed as a melt and then applied onto the core 1541 to form the coating 1542.

The coating 1542 can be applied to cover substantially the entire outer surface of the core 1541. In some embodiments, however, it may be desirable to coat most of the outer surface of the core 1541, but to leave selected uncoated regions on the outer surface of the core 1541, such as near the ends of the roll 154. The ends or faces of the core 1541 are typically also coated.

The coating 1542 is applied onto the core 1541 after a suitable surface finish has been formed on the core 1541. Typically, the core 1541 outer surface is prepared, such as by grit blasting, to provide a suitable surface for applying the coating 1542 onto the core 1541. The roughness level of the surface of the core 1541 is typically suitable to achieve sufficient mechanical interlocking with the coating 1542 to provide good adhesion.

Also, prior to preparing the core 1541 outer surface for application of the coating, the core 1541 is typically heated to stress relieve the core 1541. This heating process is referred to as heat soaking. In embodiments, the core 1541 is heated to a temperature of from about 550°C to about 900°C and maintained at this temperature for a sufficient amount of time to stress relieve the core 1541. The stress relief process enables the core 1541 to be more effectively ground to round, i.e., to a cylindrical shape having a uniform diameter along the donor roll 154. In addition, the stress relief enhances the roundness and dimensional tolerance of the as-coated donor roll 154.

After the glass material has been applied on the core 1541 to form the coating 1542, the coating 1542 is heated to a temperature range, and held at this temperature for an amount of time, that are effective to cure the glass material. Typically, the glass material can be cured by maintaining the outer coating 1542 at a temperature of

from about 900°F to about 1600°F for a period of from about 4 minutes to about 10 minutes. The curing cycle time can be adjusted to compensate for the mass of the core 1541.

For example, the exemplary soda silicate glass composition described above that does not contain Ag or Au, can typically be cured at a temperature of about 1040° F in about 10 minutes. When this composition is formed as an outer coating 1542 on the core 1541, the curing time is typically about 1 hour.

The thickness of the coating 1542 as formed on the core 1541 by the coating process is typically from about 100 μm to about 300 μm .

An unfinished donor roll typically has an arithmetic mean roughness Ra of from about 1 μm to about 2 μm . This surface smoothness level may not be completely satisfactory for some high-precision electrostatographic development applications. Accordingly, in some exemplary embodiments of the coating 1542, the coating 1542 formed on the respective core 1541 is finished by a machining process to achieve a desired final finish having a suitable low roughness. The coating 1542 provides the advantage that a highly smooth surface finish can be formed using known grinding and polishing techniques. Typically, the coating 1542 can be finished using a suitable grinding device and abrasive material, such as by diamond grinding or using abrasive powders, to achieve the desired surface roughness. In such embodiments, the final thickness of the coating 1542 is less than its applied thickness. Accordingly, the applied thickness of the coating 1542 is selected to compensate for the coating material that is removed by the finishing process.

Example

An example roll is produced by applying a silicate glass composition over a core. The glass composition is as follows: silica, about 40 wt%; soda, about 20 wt%; alumina, about 1.5 wt%; phosphate, about 4 wt%; potash, about 7 wt%; titania, about 12 wt%; vanadium penta-oxide, about 6 wt%; chromia, about 4 wt%; iron oxide, about 3.5 wt%; and Ni, about 2 wt%. The core is composed of 6061 T6 aluminum.

The roll is formed by the following process. First, the roll is cleaned by placing in an oven at a temperature of about 1040°F for about 30 minutes. A glass slurry is wet sprayed onto the roll. The roll is not grit blasted or ground prior to spraying. The roll is then placed in an oven at about 1040°F for about 1 hour under air to cure the coating. A separate roll is processed using an infrared oven instead of a

convection oven, following the same steps as above. The rolls were then subjected to finish grinding.

The coating has an electrical resistivity of about $2 \times 10^9 \Omega \cdot \text{cm}$, a capacitance of about 170 pF, and a time constant of about 0.34 seconds.

5 The coating has an Ra value of 0.53 μm and Wt value of 0.74 μm after grinding. The hardness of the coating is 60 HRC.

As described above, the glass coatings 1542 are advantageous for donor rolls 154 used in various types of scavengeless development systems, including both single and double-component developer material systems.

10 However, it will be appreciated by those skilled in the art that the coatings 1542 can be also be formed on substrates for various other applications that utilize a coating having controlled electrical properties. That is, the coatings 1542 can be used in various other applications that require a coating that can be electrically charged and discharged. For example, the coatings 1542 can be applied on rolls used
15 in imaging and printing apparatus, including color printing, that would benefit from a coating having controlled electrical properties, as well as certain mechanical, chemical and thermal properties. Such other types of rolls can be included in various types of electrostatographic imaging apparatus, including digital systems.

20 While the invention has been described in conjunction with the specific embodiments described above, it is evident that many alternatives, modifications and variations are apparent to those skilled in the art. Accordingly, the preferred embodiments of the invention as set forth above are intended to be illustrative and not limiting. Various changes can be made without departing from the spirit and scope of the invention.

WHAT IS CLAIMED IS:

1. A roll, comprising:
a core; and
a coating comprising a glass material formed over the core, wherein the
5 glass material can be electrically charged and discharged.
2. The roll of claim 1, wherein the glass material is a silicate glass.
3. The roll of claim 2, wherein the glass material comprises:
silica, from about 40 mol% to about 95 mol%;
soda, from about 5 mol% to about 60 mol%;
10 alumina, from 0 to about 7 mol%;
phosphate, from 0 to about 5 mol%;
potash, from 0 to about 10 mol%;
titania, from 0 to about 20 mol%;
vanadium penta-oxide, from 0 to about 10 mol%;
15 chromia, from 0 to about 8 mol%;
iron oxide, from 0 to about 5 mol%;
nickel, from 0 to about 5 mol%;
silver, from 0 to about 5 mol%; and
gold, from 0 to about 5 mol%.
- 20 4. The roll of claim 3, wherein the glass material comprises:
silica, about 40 wt%;
soda, about 20 wt%;
alumina, about 1.5 wt%;
phosphate, about 4 wt%;
25 potash, about 7 wt%;
titania, about 12 wt%;
vanadium penta-oxide, about 6 wt%;
chromia, about 4 wt%;
iron oxide, about 3.5 wt%; and
30 NiO (Nickel Oxide), about 2 wt%.
5. The roll of claim 1, wherein the coating consists essentially of a silicate
glass.

6. The roll of claim 1, wherein the coating has an arithmetical mean roughness Ra of less than about 1 μm and a maximum waviness of less than about 1 μm .

7. The roll of claim 1, wherein the coating has an electrical resistivity of from about $1 \times 10^5 \Omega\cdot\text{cm}$ to about $1 \times 10^{14} \Omega\cdot\text{cm}$.

8. The roll of claim 1, wherein the coating has a hardness of at least about 4 GPa Knoop

9. The roll of claim 1, wherein the core has a first coefficient of thermal expansion and the coating has a second coefficient of thermal expansion that differs from the first coefficient of thermal expansion by less than about 1 ppm/ $^{\circ}\text{C}$.

10. The roll of claim 1, wherein the glass material is chemically resistant to toner and paper fibers.

11. The roll of claim 1, wherein the core comprises a metal.

12. The roll of claim 1, wherein the core comprises a non-metallic material having a metal coating on which the coating is formed.

13. An electrostatographic imaging apparatus comprising a roll according to claim 1.

14. A charge donor roll, comprising:

a core; and

a coating comprising a glass material formed over the core, wherein the coating can be electrically charged and discharged.

15. The charge donor roll of claim 14, wherein the glass material is a silicate glass.

16. The charge donor roll of claim 15, wherein the glass material comprises:

silica, from about 40 mol% to about 95 mol%;

soda, from about 5 mol% to about 60 mol%;

alumina, from 0 to about 7 mol%;

phosphate, from 0 to about 5 mol%;

potash, from 0 to about 10 mol%;

titania, from 0 to about 20 mol%;

vanadium penta-oxide, from 0 to about 10 mol%;

chromia, from 0 to about 8 mol%;

iron oxide, from 0 to about 5 mol%;
nickel, from 0 to about 5 mol%;
silver, from 0 to about 5 mol%; and
gold, from 0 to about 5 mol%.

5 17. The charge donor roll of claim 16, wherein the glass material comprises:

silica, about 40 wt%;
soda, about 20 wt%;
alumina, about 1.5 wt%;
10 phosphate, about 4 wt%;
potash, about 7 wt%;
titania, about 12 wt%;
vanadium penta-oxide, about 6 wt%;
chromia, about 4 wt%;
15 iron oxide, about 3.5 wt%; and
Ni, about 2 wt%.

18. The charge donor roll of claim 14, wherein the coating consists essentially of a silicate glass.

19. The charge donor roll of claim 14, wherein the coating has an
20 arithmetical mean roughness Ra of less than about 1 μm and a maximum waviness of less than about 1 μm .

20. The charge donor roll of claim 14, wherein the coating has an electrical resistivity of from about $1 \times 10^5 \Omega\text{-cm}$ to about $1 \times 10^{14} \Omega\text{-cm}$.

21. The charge donor roll of claim 14, wherein the coating has a hardness
25 of at least about 4 GPa Knoop.

22. The charge donor roll of claim 14, wherein the core has a first coefficient of thermal expansion and the outer coating has a second coefficient of thermal expansion that differs from the first coefficient of thermal expansion by less than about 1 ppm/ $^{\circ}\text{C}$.

23. The charge donor roll of claim 14, wherein the glass material is
30 chemically resistant to toner and paper fibers.

24. The charge donor roll of claim 14, wherein the core comprises a metal.

25. The charge donor roll of claim 14, wherein the core comprises a non-metallic material having a metal coating on which the coating is formed.

26. An electrostatographic imaging apparatus comprising a charge donor roll according to claim 14.

5 27. A method of making a roll, comprising forming a coating over a core, the coating comprising a glass material that can be electrically charged and discharged.

28. The method of claim 27, wherein the coating consists essentially of a glass material.

10 29. The method of claim 27, wherein the glass material is a silicate glass.

30. The method of claim 29, wherein the glass material comprises:

silica, from about 40 mol% to about 95 mol%;

soda, from about 5 mol% to about 60 mol%;

alumina, from 0 to about 7 mol%;

15 phosphate, from 0 to about 5 mol%;

potash, from 0 to about 10 mol%;

titania, from 0 to about 20 mol%;

vanadium penta-oxide, from 0 to about 10 mol%;

chromia, from 0 to about 8 mol%;

20 iron oxide, from 0 to about 5 mol%;

nickel, from 0 to about 5 mol%;

silver, from 0 to about 5 mol%; and

gold, from 0 to about 5 mol%.

31. The method of claim 30, wherein the glass material comprises:

25 silica, about 40 wt%;

soda, about 20 wt%;

alumina, about 1.5 wt%;

phosphate, about 4 wt%;

potash, about 7 wt%;

30 titania, about 12 wt%;

vanadium penta-oxide, about 6 wt%;

chromia, about 4 wt%;

iron oxide, about 3.5 wt%; and

Ni, about 2 wt%.

32. The method of claim 27, wherein the coating consists essentially of a silicate glass.

33. The method of claim 27, wherein the coating has an arithmetical mean roughness Ra of less than about 1 μm and a maximum waviness of less than about 1 μm .

34. The method of claim 27, wherein the coating has an electrical resistivity of from about $1 \times 10^5 \Omega\text{-cm}$ to about $1 \times 10^{14} \Omega\text{-cm}$.

35. The method of claim 27, wherein the coating has a hardness of at least about 4 GPa Knoop.

36. The method of claim 27, wherein the core has a first coefficient of thermal expansion and the coating has a second coefficient of thermal expansion that differs from the first coefficient of thermal expansion by less than about 1 ppm/ $^{\circ}\text{C}$.

37. The method of claim 27, wherein the glass material is chemically resistant to toner and paper fibers.

38. The method of claim 27, wherein the coating is applied on the core by electrostatic spraying.

39. The method of claim 27, wherein the coating is applied on the core by wet spraying.

40. The method of claim 27, wherein the core comprises an electrically conductive material on which the outer coating is applied.

41. The method of claim 27, wherein the core comprises a metal outer surface on which the coating is formed.

5

5

FIG. 1

FIG. 2

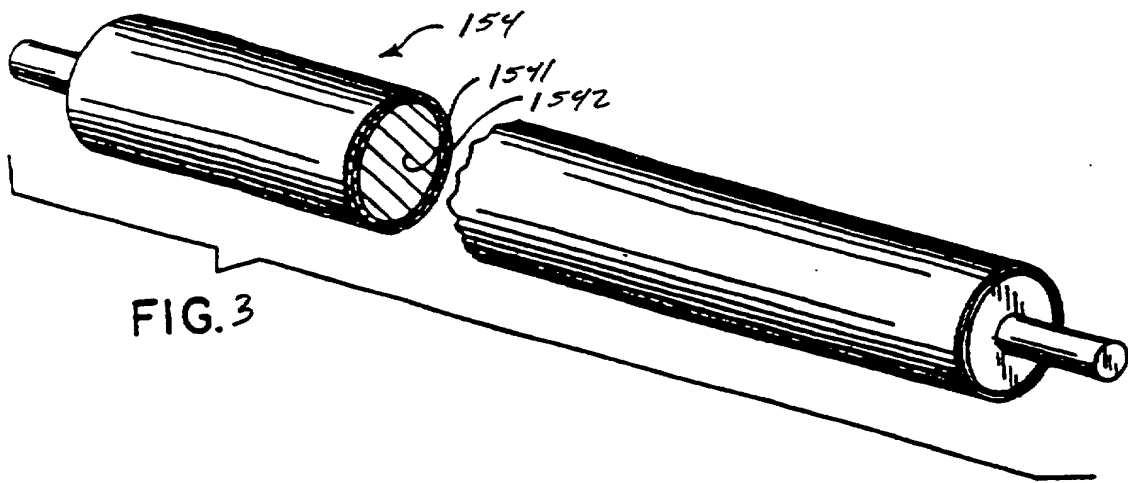


FIG. 3

APPLICATION FOR UNITED STATES PATENT DECLARATION AND POWER OF ATTORNEY

As a below named inventor, I hereby declare that:

My residence, post office address and citizenship are as stated below next to my name; that

I verily believe I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural inventors are named below) of the subject matter which is claimed and for which a patent is sought on the invention entitled:

ROLL HAVING GLASS COATING

described and claimed in the specification:

Check one

*a. ☒ attached hereto.

b. ☐ filed on _____ as Application No. _____ and amended on _____ (if applicable).

I hereby state that I have reviewed and understand the contents of the above-identified specification, including the claims, as amended by any amendment referred to above.

I acknowledge the duty to disclose to the Office all information known to me to be material to patentability as defined in Title 37, Code of Federal Regulations, §1.56. Under Title 35, U.S. Code §119, the priority benefits of the following foreign application(s) and/or United States provisional application(s) filed by me or my legal representatives or assigns within one year prior to this application are hereby claimed:

The following application(s) for patent or inventor's certificate on this invention were filed in countries foreign to the United States of America either (a) more than one year prior to this application, or (b) before the filing date of the above-named foreign priority application(s) and/or United States provisional application(s):

I hereby appoint the following as my attorneys of record with full power of substitution and revocation to prosecute this application and to transact all business in the Patent Office:

**James A. Oliff, Registration No. 27,075;
William P. Berridge, Registration No. 30,024;
Kirk M. Hudson, Registration No. 27,562;
Thomas J. Pardini, Registration No. 30,411;
Edward P. Walker, Registration No. 31,450;
Robert A. Miller, Registration No. 32,771;
Mario A. Costantino, Registration No. 33,565;
Stephen J. Roe, Registration No. 34,463; and
John Beck, Registration No. 22,833.**

ALL CORRESPONDENCE IN CONNECTION WITH THIS APPLICATION SHOULD BE SENT TO OLIFF & BERRIDGE, PLC, P.O. BOX 19928, ALEXANDRIA, VIRGINIA 22320, TELEPHONE (703) 836-6400.

I hereby declare that I have reviewed and understand the contents of this Declaration, and that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

**1 Typewritten Full Name
of First or Sole Inventor**

<i>of First or Sole Inventor</i>		Christopher	D.	BLAIR
		Given Name	Middle Initial	Family Name
2	**INVENTOR'S SIGNATURE:	<i>Christopher D Blair</i>		
3	**DATE OF SIGNATURE:	<i>May</i>	<i>26</i>	<i>2000</i>
		Month	Day	Year
Residence:	Ontario	New York	USA	
	City	State or Province	Country	
Citizenship:	USA			
	Post Office Address:			
	(Insert complete mailing address, including country)	499 Ridge Road		
		Ontario, New York 14519		

***This form may be executed only when attached to the specification (including claims) at the end thereof if Box a. is checked.**

****Note to Inventor: Please sign name exactly as it appears above and insert actual date of signing.**

IF THERE IS MORE THAN ONE INVENTOR USE PAGE 2 AND PLACE AN "X" HERE ☒

Page 2 OF U.S.A. DECLARATION FORM
(Discard this page in a sole inventor application)

1 **Typewritten Full Name**
of Second Joint Inventor (if any)

Timothy	R.	JASKOWIAK
Given Name	Middle Initial	Family Name

2 ****INVENTOR'S SIGNATURE:**

Timothy R. Jaskowiak

3 ****DATE OF SIGNATURE:**

5	30	2000
Month	Day	Year

Residence:	Webster	New York	USA
	City	State or Province	Country

Citizenship: USA

Post Office Address:

(Insert complete
mailing address,
including country)

203 Lake Road

Webster, New York 14580

1 **Typewritten Full Name**
of Third Joint Inventor (if any)

Given Name	Middle Initial	Family Name

2 ****INVENTOR'S SIGNATURE:**

3 ****DATE OF SIGNATURE:**

Month	Day	Year

Residence:			
	City	State or Province	Country

Citizenship:

Post Office Address:

(Insert complete
mailing address,
including country)

1 **Typewritten Full Name**
of Fourth Joint Inventor (if any)

Given Name	Middle Initial	Family Name

2 ****INVENTOR'S SIGNATURE:**

3 ****DATE OF SIGNATURE:**

Month	Day	Year

Residence:			
	City	State or Province	Country

Citizenship:

Post Office Address:

(Insert complete
mailing address,
including country)

1 **Typewritten Full Name**
of Fifth Joint Inventor (if any)

Given Name	Middle Initial	Family Name

2 ****INVENTOR'S SIGNATURE:**

3 ****DATE OF SIGNATURE:**

Month	Day	Year

Residence:			
	City	State or Province	Country

Citizenship:

Post Office Address:

(Insert complete
mailing address, including

country)

****Note to Inventors:** Please sign name exactly as it appears and insert the actual date of signing.
This form may be executed only when attached to the first page of the Declaration and Power of Attorney form and the specification (including claims) of the application to which it pertains.

007650-6268560